

WHAT IS CLAIMED IS:

1. A method of manufacturing a display device,
comprising:

5 the step of preparing a member having, on a
separation layer, a semiconductor film having a first
region with a switching element and a second region
with a peripheral circuit;

the step of forming an image display portion on
the first region; and

10 the separation step of separating the first and
second regions from the member together with the image
display portion.

2. The method according to claim 1, wherein the
member is obtained by forming a porous layer on a
15 surface of a semiconductor substrate, forming the
semiconductor film on a surface of the porous layer,
and then forming the first and second regions.

3. The method according to claim 2, wherein the
semiconductor film is formed on the surface of the
20 porous layer after forming a protective film on inner
walls of pores in the porous layer.

4. The method according to claim 1, wherein the
member is obtained by forming the first and second
regions on a surface of a semiconductor substrate and
25 implanting ions from the surface side to a
predetermined depth to form the separation layer.

5. The method according to claim 2, wherein the

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semiconductor substrate is a single-crystal silicon substrate or a compound semiconductor substrate.

6. The method according to claim 4, wherein the semiconductor substrate is a single-crystal silicon substrate or a compound semiconductor substrate.

7. The method according to claim 1, wherein the separation step is executed by injecting a fluid formed from a liquid or gas to or near a side surface of the separation layer.

8. The method according to claim 1, wherein the separation step is executed under a static pressure.

9. The method according to claim 1, wherein the member is formed again using a remaining member which remains after the first and second regions are separated from the member.

10. A display device comprising:

a semiconductor film laid out on a separation surface and having a first region with a switching element and a second region with a peripheral circuit;

and

an image display portion laid out on the first region.